

# **MOSFET**

Metal Oxide Semiconductor Field Effect Transistor

# **Bare Die**

OptiMOS™3 Power MOS Transistor Chip IPC300N20N3

# **Data Sheet**

Rev. 2.5 Final



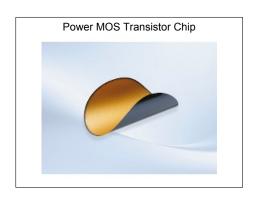
## IPC300N20N3

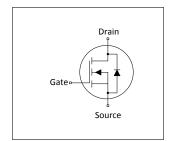
#### **Description** 1

- N-channel enhancement mode
- For additional characteristics and max rating refer to the datasheet of IPP110N20N3 G
- AQL 0.65 for visual inspection according to failure catalogue
- Electrostatic Discharge Sensitive Device according to MIL-STD 883C
  Die bond: soldered or glued
- · Backside metallization: NiV system
- Frontside metallization: AlSiCu system
- Passivation: nitride + imide (only on edge structure)
- Package: sawn on foil



Table 1 Roy 1 of formation 1 aramotore					
Parameter	Value	Unit			
$V_{(BR)DSS}$	200	V			
R <sub>DS(on)</sub>	11 <sup>1)</sup>	mΩ			
Die size	6 x 5	mm <sup>2</sup>			
Thickness	250	μm			











Type / Ordering Code	Package	Marking	Related Links
IPC300N20N3	Chip	not defined	-

## **Electrical Characteristics on Wafer Level**

at  $T_i = 25$ °C, unless otherwise specified

Table 2

Davamatav	Symbol		Values		l lmi4	Note / Test Condition
Parameter		Min.	Тур.	Max.	Unit	Note / Test Condition
Drain-source breakdown voltage	V <sub>(BR)DSS</sub>	200	-	-	V	V <sub>GS</sub> =0 V ,I <sub>D</sub> =1 mA
Gate threshold voltage	V <sub>GS(th)</sub>	2	3	4	V	V <sub>DS</sub> =V <sub>GS</sub> , I <sub>D</sub> =270 μA
Zero gate voltage drain current	I <sub>DSS</sub>	_	0.1	1	μΑ	V <sub>GS</sub> =0 V ,V <sub>DS</sub> =160 V
Gate-source leakage current	I <sub>GSS</sub>	_	1	100	nA	V <sub>GS</sub> =20 V ,V <sub>DS</sub> =0 V
Drain-source on- resistance	R <sub>DS(on)</sub>	_	9.22)	100 <sup>3)</sup>	mΩ	V <sub>GS</sub> =10 V ,I <sub>D</sub> =2.0 A
Reverse diode forward on-voltage	<b>V</b> <sub>SD</sub>	_	1.0	1.2	V	V <sub>GS</sub> =0 V ,I <sub>F</sub> =1A
Avalanche energy, single pulse	<b>E</b> <sub>AS</sub>	-	40 <sup>4)</sup>	-	mJ	$I_D$ =30 A, $R_{GS}$ =25 $\Omega$

 $<sup>^{1)}</sup>$  packaged in a P-TO220-3 (see ref. product) typical bare die  $R_{\rm DS(on)};\ V_{\rm GS}{=}10\ {\rm V}$ 

<sup>3)</sup> limited by wafer test-equipment

<sup>4)</sup> Wafer tested. For general avalanche capability refer to the datasheet of IPP110N20N3 G



## 3 Package Outlines

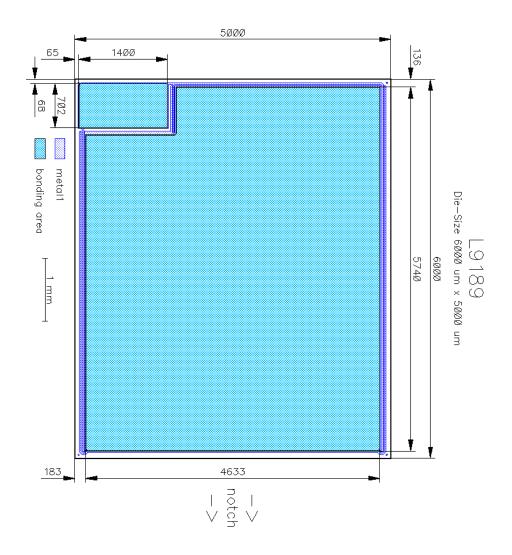


Figure 1 Outline Chip, dimensions in µm



## OptiMOS™3 Power MOS Transistor Chip

IPC300N20N3

### **Revision History**

IPC300N20N3

Revision: 2014-07-23, Rev. 2.5

Previous Revision				
Revision	Date	Subjects (major changes since last revision)		
2.5	2014-07-23	Release Final Version		

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